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Correction: Vertical sidewall electrodes monolithically integrated into 3D glass microfluidic chips using water-assisted femtosecond-laser fabrication for *in situ* control of electrotaxis

 Jian Xu,^{*a} Dong Wu,^a Joanna Y. Ip,^b Katsumi Midorikawa^a and Koji Sugioka^{*a}

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 Correction for 'Vertical sidewall electrodes monolithically integrated into 3D glass microfluidic chips using water-assisted femtosecond-laser fabrication for *in situ* control of electrotaxis' by Jian Xu *et al.*, *RSC Adv.*, 2015, 5, 24072–24080.

In the footnote giving details of the electronic supplementary information on page 1 of the original paper, the sentence 'A movie of the *in situ* control of electrotaxis of *C. elegans* and subsequent electroless plating of sidewalls using an electrofluidic device' should read 'A movie of the *in situ* control of electrotaxis of *C. elegans* using an electrofluidic device'.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

^aRIKEN Center for Advanced Photonics, 2-1 Hirosawa, Wako, Saitama 351-0198, Japan. E-mail: ksugioka@riken.jp; jxu@riken.jp; Fax: +81 48 462 4682; Tel: +81 48 467 9495

^bRNA Biology Laboratory, RIKEN, 2-1 Hirosawa, Wako, Saitama 351-0198, Japan

